

Title: A high-resolution CMOS imaging detector for the search of neutrinoless double beta decay in Se-82

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Abstract:

# **An imaging detector for the search of neutrinoless $\beta\beta$ decay**

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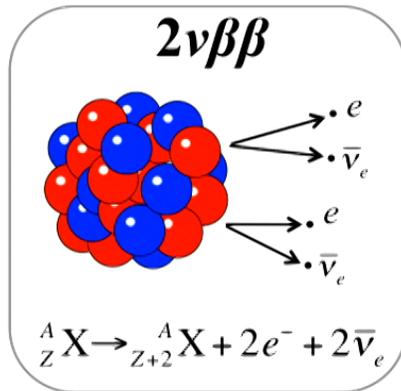
# Outline

- The search for neutrinoless  $\beta\beta$  decay.
- Particle detection in an imaging device.
- Current amorphous Se (aSe) imaging technology.
- Background estimates for a large CMOS /  $^{82}\text{Se}$  imaging array.
- Near term R&D efforts and prospects.

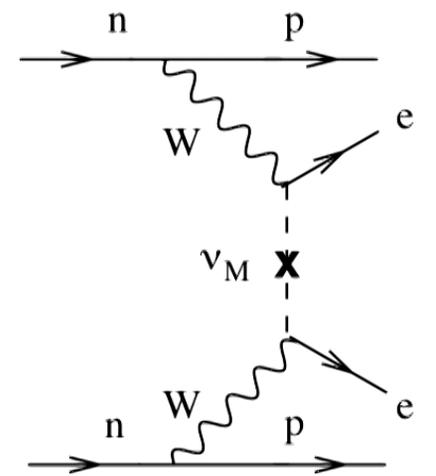
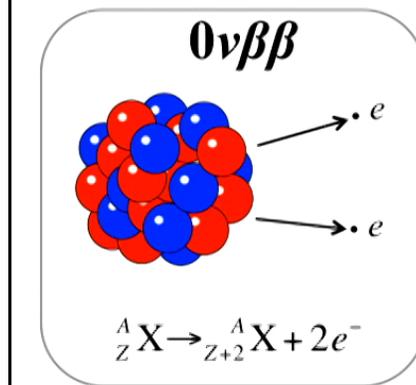


# $0\nu\beta\beta$ decay

Standard process



BSM: Majorana vs



Decay rate  $\downarrow$   $\Gamma_{0\nu}$

Phase space factor  $\swarrow$   $G_{0\nu}$

Nuclear matrix element (NME)  $\nearrow$   $\mathcal{M}^2$

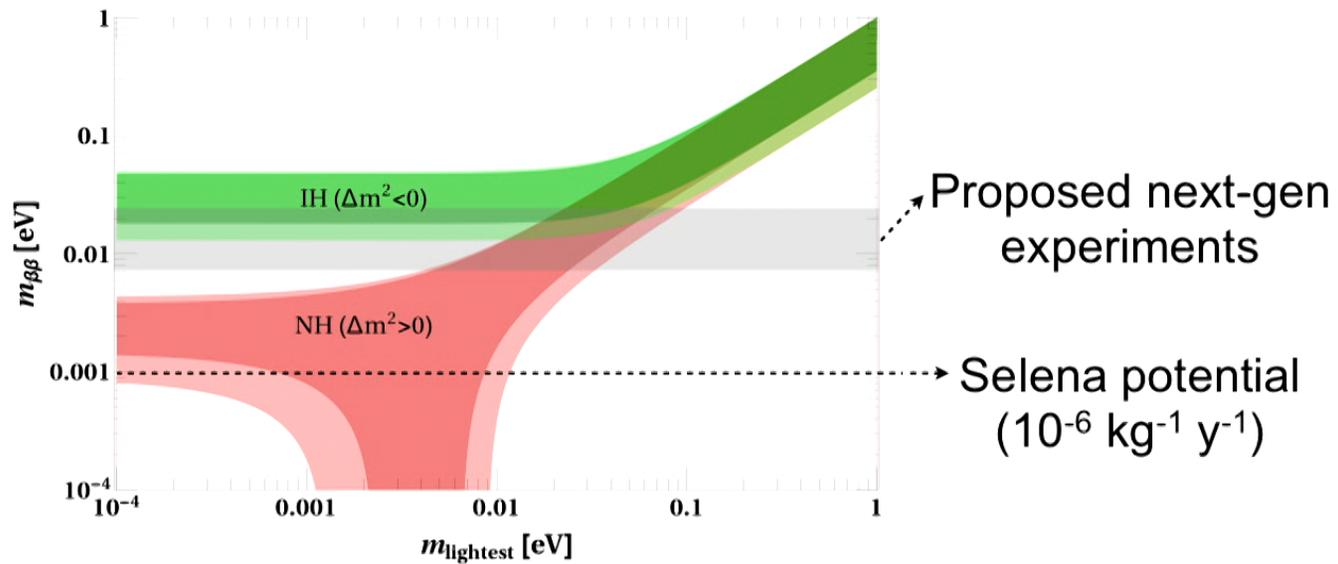
$$\Gamma_{0\nu} = G_{0\nu} \mathcal{M}^2 \left| \frac{m_{\beta\beta}}{m_e} \right|^2$$

Particle physics:

$$m_{\beta\beta} \equiv \left| \sum_{i=1,2,3} U_{ei}^2 m_i \right|$$

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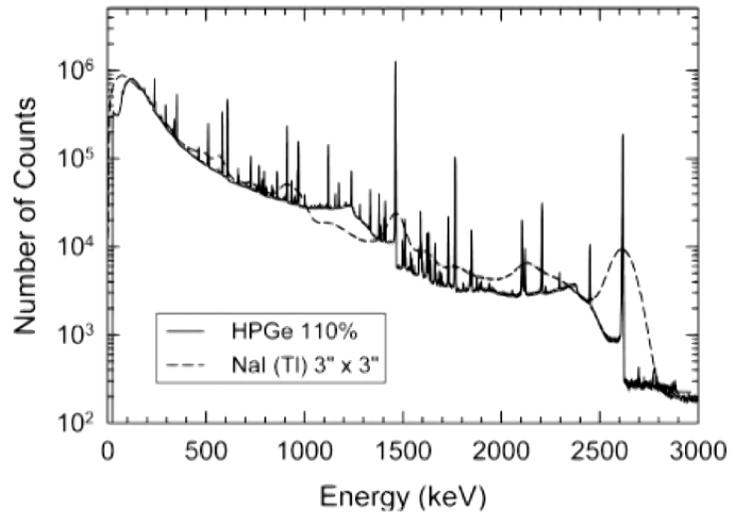
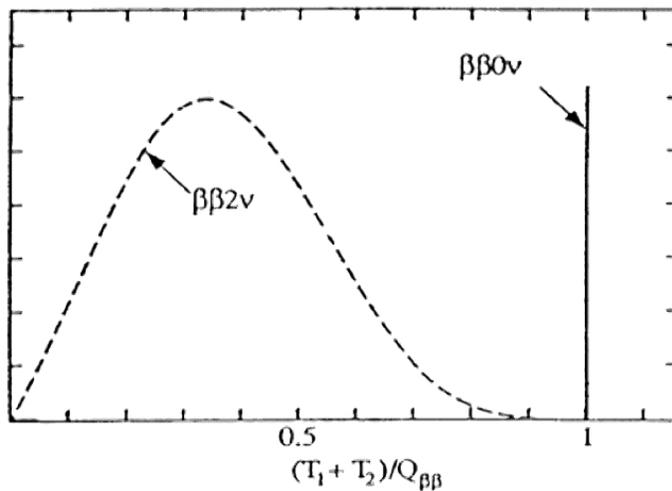
# Parameter space



The field is crowded... with experimental proposals that won't answer the question if the neutrino mass hierarchy is normal.

# Strategy

Good energy resolution to distinguish neutrinoless decay



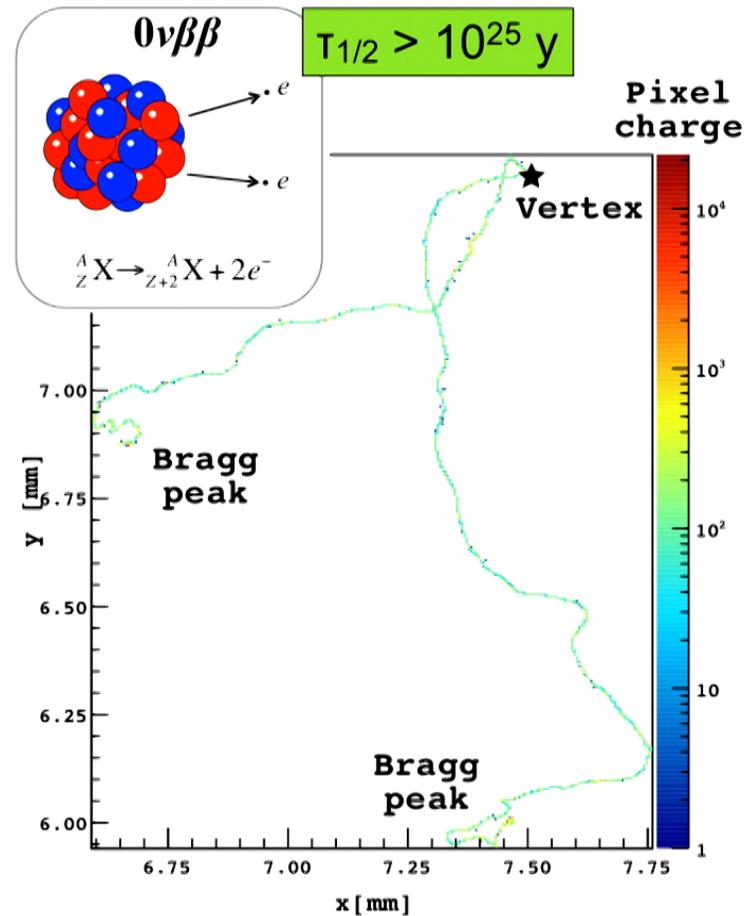
High Q-value to avoid background from U+Th

Not all isotopes are equal: phase-space factors, NMEs and number densities vary between  $\beta\beta$  isotopes. E.g. for the same  $m_{\beta\beta}$ , decay rate is 2.5x higher in  $^{82}\text{Se}$  than  $^{136}\text{Xe}$ .

# $0\nu\beta\beta$ decay in $^{82}\text{Se}$

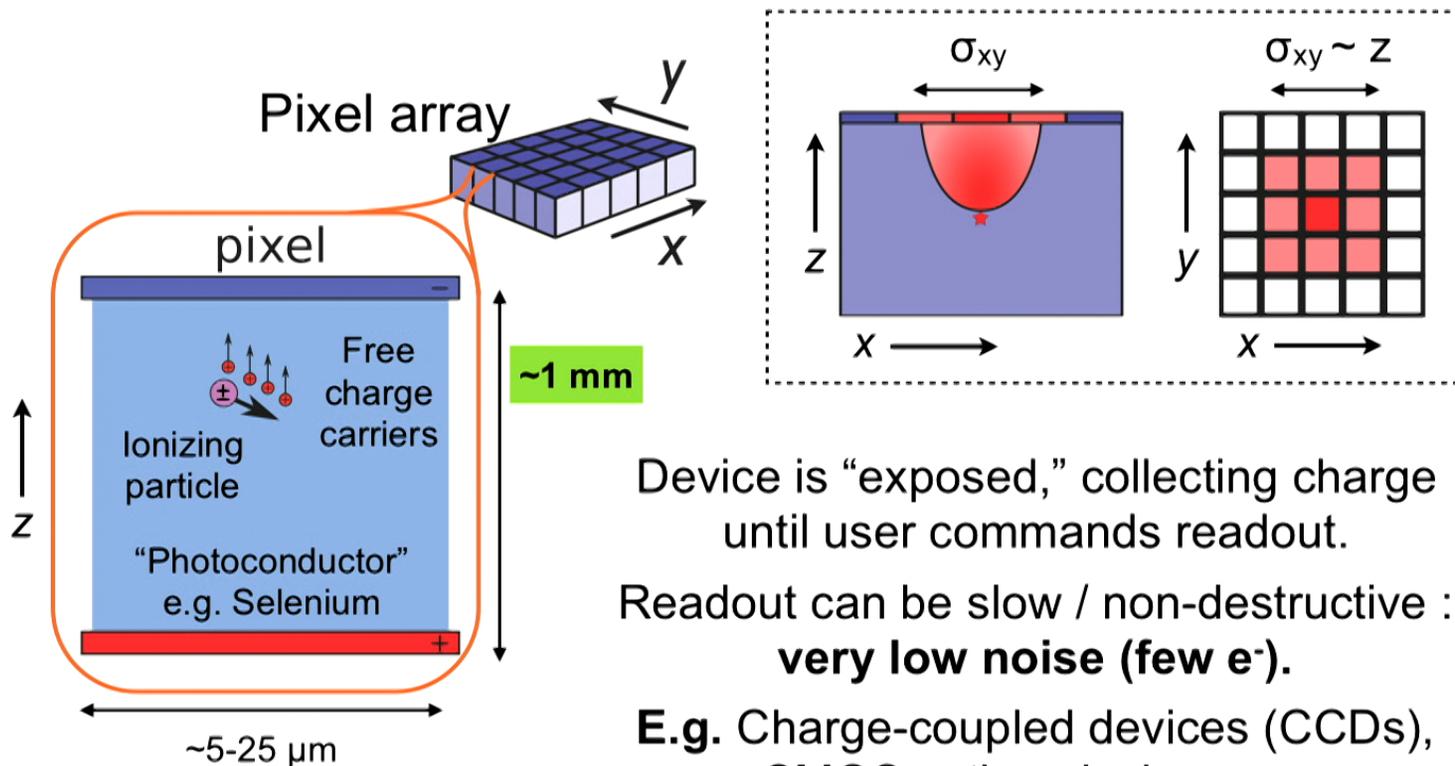
An amorphous  $^{82}\text{Se}$  / CMOS active pixel array to image, with high spatial and energy resolution, the two electrons with energy  $Q_{\beta\beta}$  from the neutrinoless  $\beta\beta$  decay of  $^{82}\text{Se}$ .

Potential to achieve the low backgrounds necessary  $<10^{-6} \text{ kg}^{-1}\text{y}^{-1}$  to test if neutrinos are Majorana if the hierarchy of neutrino masses is normal.



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# Imaging detector



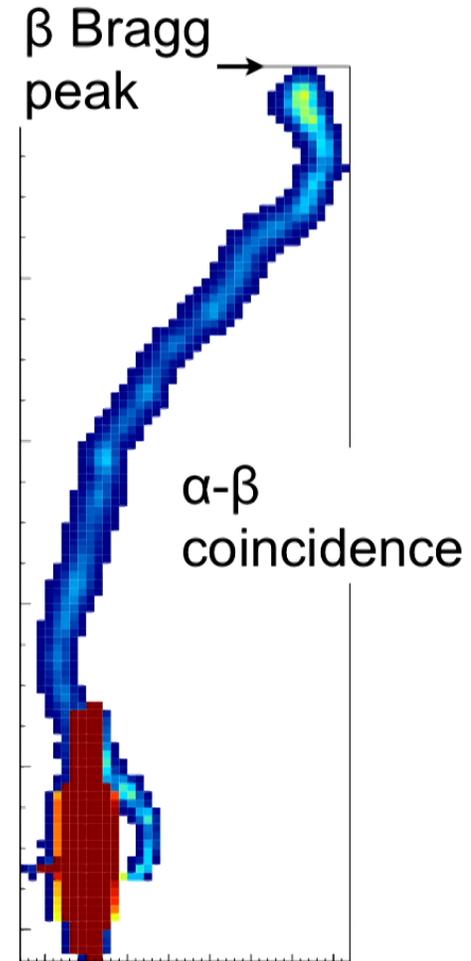
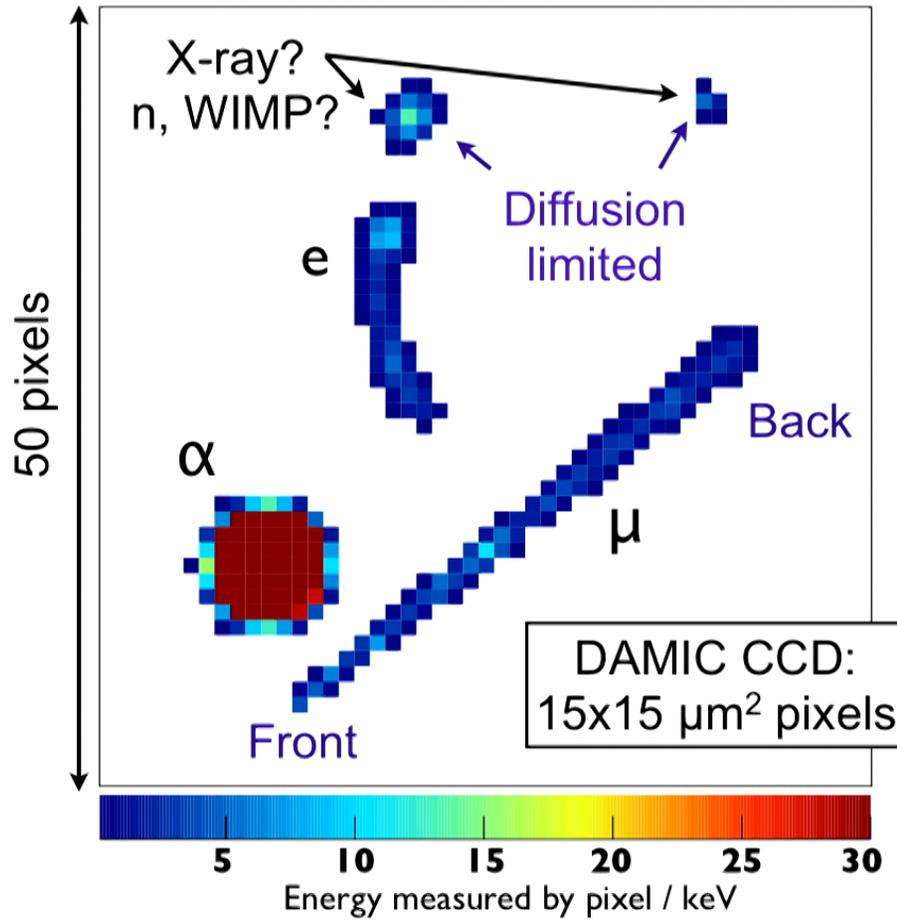
Device is "exposed," collecting charge until user commands readout.

Readout can be slow / non-destructive :  
**very low noise (few  $e^-$ ).**

**E.g.** Charge-coupled devices (CCDs), CMOS active pixel arrays.

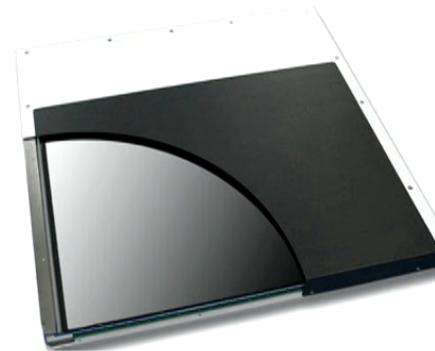
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# Particle tracks



# Amorphous Se detectors

Se X-ray detectors are used in medical imaging.  
720 cm<sup>2</sup>, 1 mm-thick.  
Pixel size: 85 μm x 85 μm.

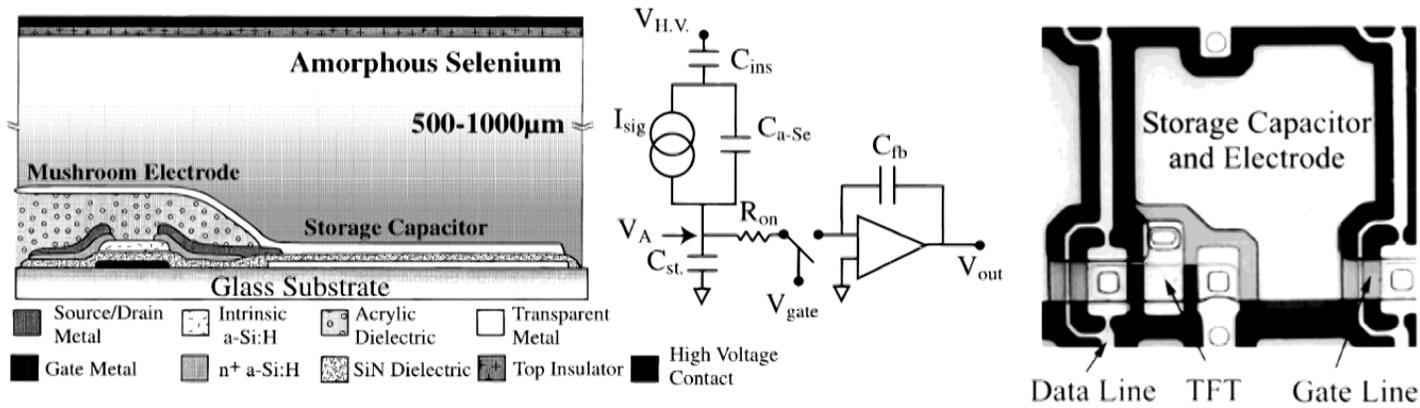


Operated at high electric fields ( $\sim 10^5$  V/μm) and  $\sim 50$  e-h pair per keV for 140 keV X-rays.

Large band gap: Negligible bulk dark current at room temperature.

**Present limitation:** 1000 e-h RMS noise per pixel (from readout and leakage current).

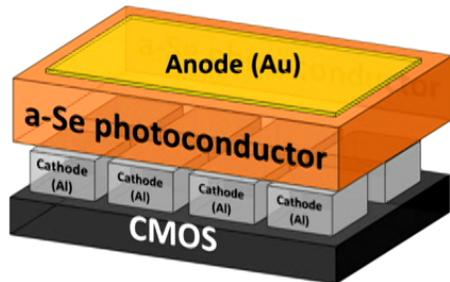
# Existing technology



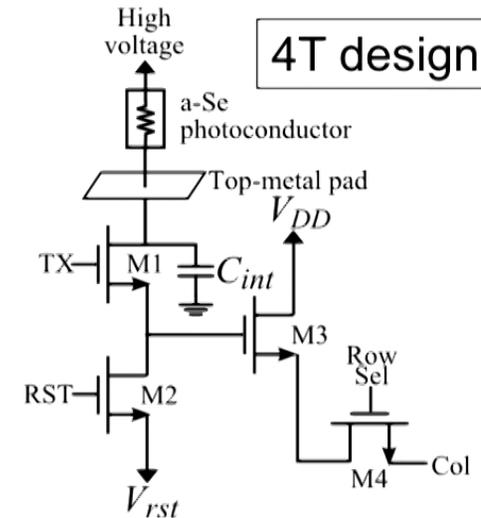
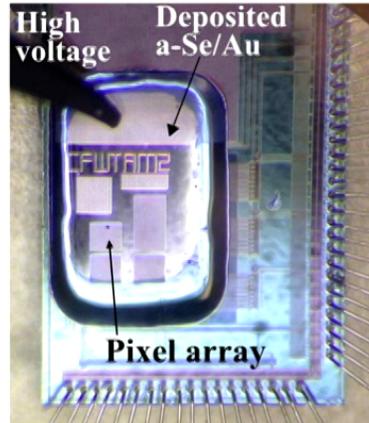
Replace current TFT pixel array on glass substrate for CMOS active pixel array on silicon substrate for lower-noise and more functionality.

Other requirement: Storage electrode / pixel structure must be a few µm thick.

# CMOS aSe imager

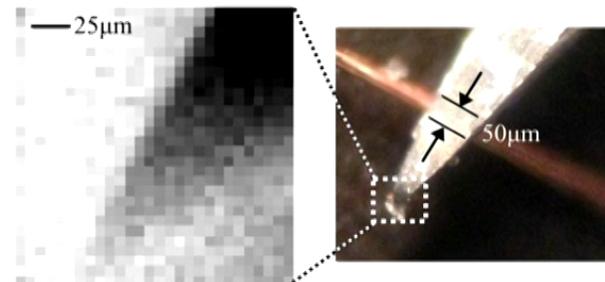


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DOI: 10.1109/LED.2015.2410304



Already implemented for small test arrays with 50  $\mu\text{m}$ -thick aSe.  
Down to 6x6  $\mu\text{m}^2$ , 20  $e^-$  noise. Up to 22 s integration time.

Low cost, scalable technology.  
Possible functionality: A/D conversion  
and zero suppression on board.

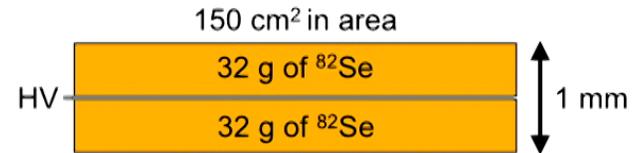


# Selenium-82

- High Q-value (3 MeV, above most  $\gamma$ s from uranium and thorium),  $10^{20}$  y  $2\nu$  half-life, and 9% natural abundance.
- Se can form many gaseous compounds: e.g. selenium hexafluoride, hydrogen selenide, dimethyl selenide.
- Thus, isotopic separation by centrifugation or distillation are possible (Data hints at significant isotopic separation in hydrogen selenide with a meter-long column).
- Elemental selenium has been successfully purified by float-zone process (can be very radio-pure).

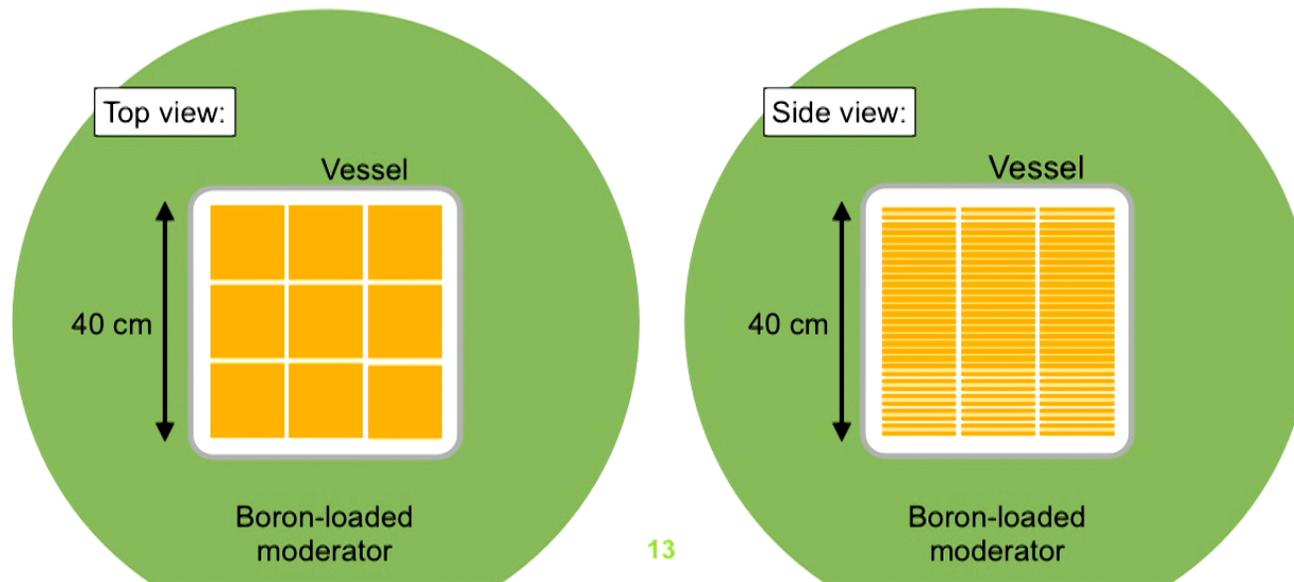
# Detector array e.g.

Rectangular CMOS pixel arrays with  $^{82}\text{Se}$  evaporated on pixel structure.



Starting from 200 mm Si wafers. Digitization and zero-suppression on board.

~160 kg target ~2500 modules ~75 m<sup>2</sup> imaging area



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# 2ν background

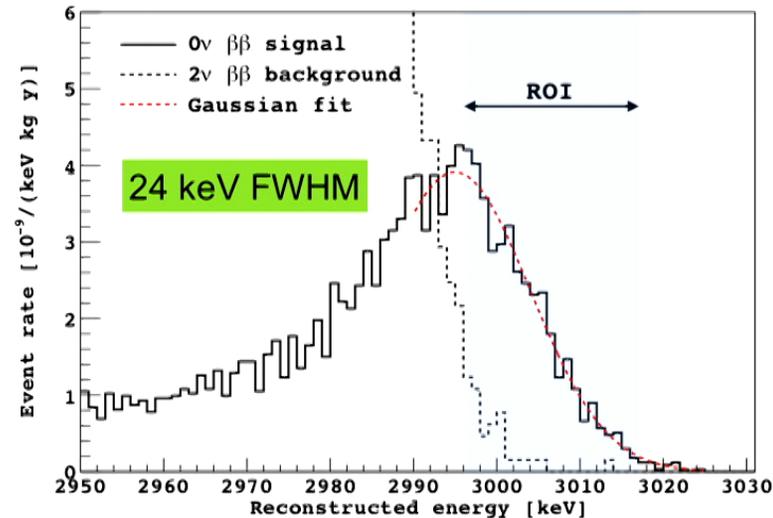
Full simulation:

CMOS properties:

10 e<sup>-</sup> noise  
70 dB dynamic range  
15x15 μm<sup>2</sup>  
5 μm-thick pixel array

Amorphous Se:  
200 μm thick  
15 eV per e-h pair  
Fano = 0.6

For  $m_{\beta\beta} = 1 \text{ meV}/c^2$  and  $g_{\text{phen.}}$   
(most unfavorable case)



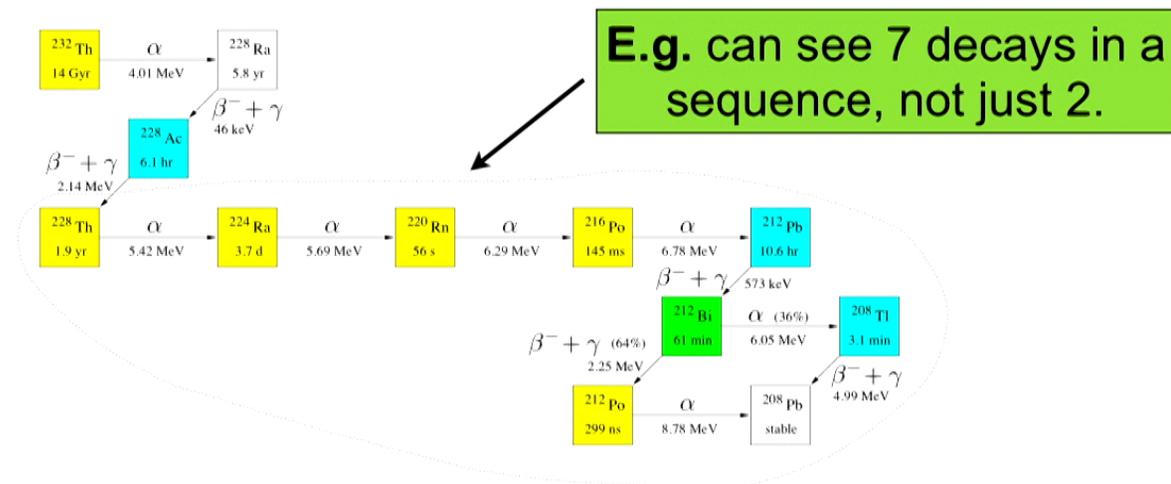
For  $m_{\beta\beta} = 1 \text{ meV}/c^2$  and  $g_{\text{phen.}}$  ( $g_{\text{nucl.}}$ ):  
 $0\nu\beta\beta$  decay signal:  $4 (160) \times 10^{-8} /(\text{kg y})$

$2\nu\beta\beta$  decay background:  $5 \times 10^{-9} /(\text{kg y})$

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# Background suppression

- The high spatial resolution of imaging devices allows for particle identification based on the topology of the ionization track.
- Precise determination of a radioactive decay site (+ solid-state device) allows for superb efficiency in the identification of radioactive decay sequences.



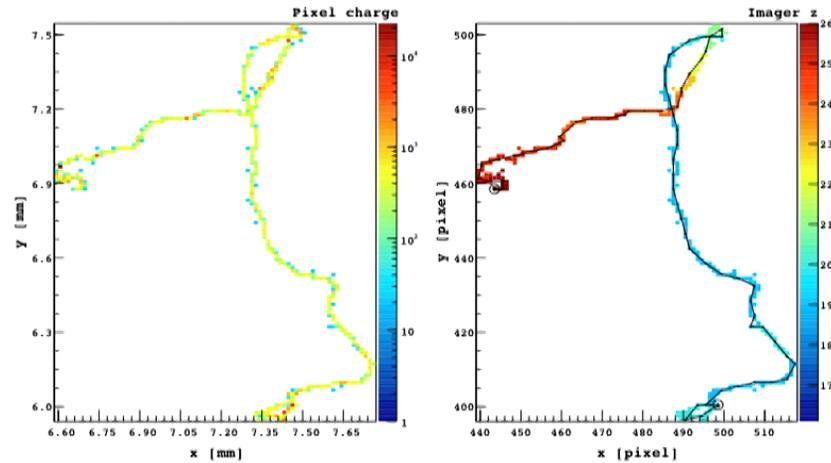
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# Single/double electron

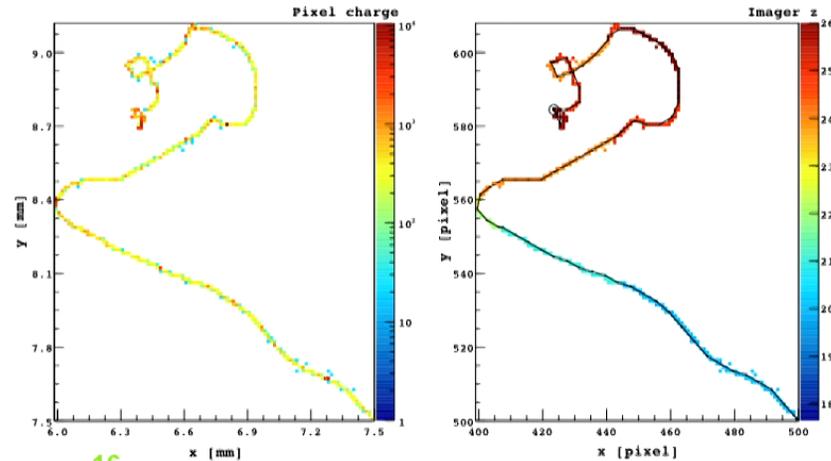
From simulation:  
By identification of  
Bragg peak have  
achieved  $10^{-3}$   
suppression of single  
electron background,  
with 50% signal  
acceptance.

Strongly suppresses  
 $\gamma$ -ray and single  $\beta$   
backgrounds

Double electron



Single electron



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# Radioactive backgrounds

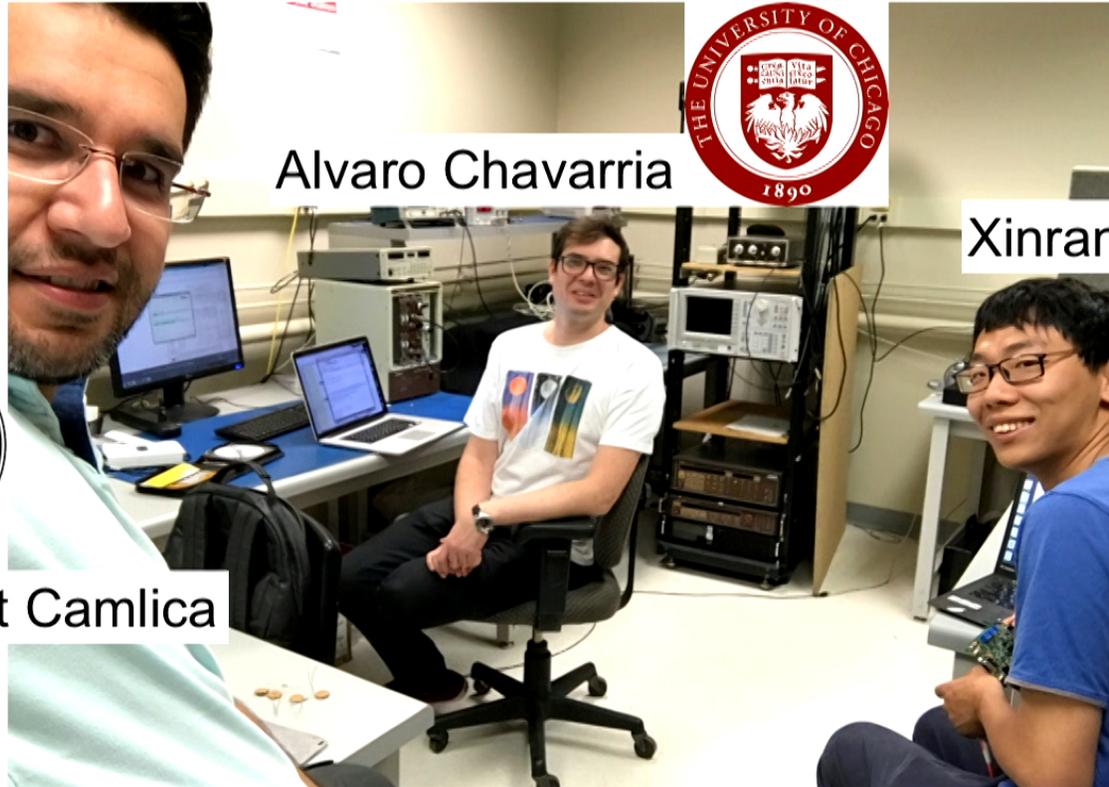
In ROI Source	Raw background rate / $\text{kg}^{-1}\text{y}^{-1}$	After discrimination / $\text{kg}^{-1}\text{y}^{-1}$
$\beta$ -decay (bulk)	$< 3.3 \times 10^{-1}$	$< 3.7 \times 10^{-9}$
$\beta$ -decay (surface)	$< 4.1 \times 10^{-1}$	$< 1.2 \times 10^{-8}$
$\beta$ -decay (cosmo.)	$< 9.9 \times 10^{-5}$	$< 1.5 \times 10^{-7}$
$\gamma$ -ray (photo-elec.)	$< 7.2 \times 10^{-4}$	$< 7.2 \times 10^{-7}$
$\gamma$ -ray (Compton)	$< 1.6 \times 10^{-3}$	$< 4.1 \times 10^{-7}$
$\gamma$ -ray (pair prod.)	$< 1.9 \times 10^{-6}$	$< 1.9 \times 10^{-7}$
<b>Total</b>	<b><math>&lt; 7.4 \times 10^{-1}</math></b>	<b><math>&lt; 1.5 \times 10^{-6}</math></b>

Bulk backgrounds suppressed by  $\alpha/\beta$  particle ID and spatial coincidences.

Also applied multiple scattering cut, limited to  $10^{-1}$  suppression of nearby scatters.

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# R&D



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Xinran Li

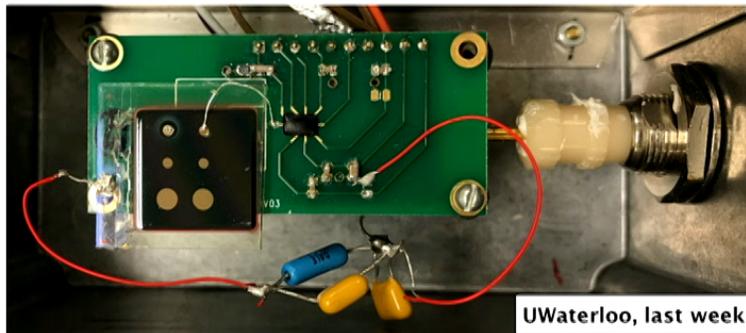
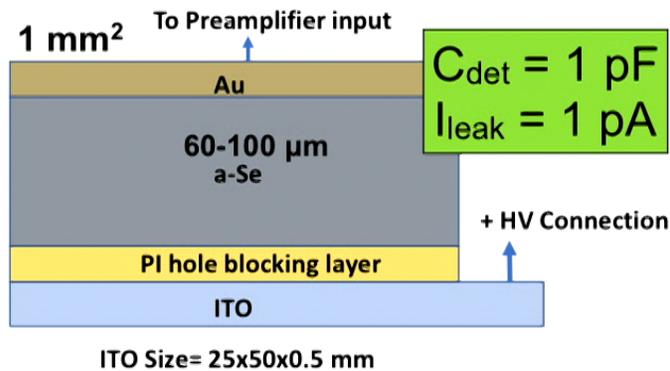


Ahmet Camlica

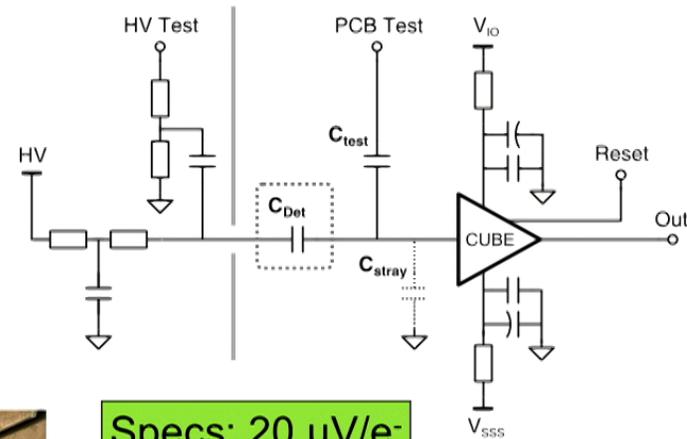
Not Pictured: C. Galbiati, K.S. Karim, P. Privitera

# Establish E response

## Detector:



## Front-end from XGLab:

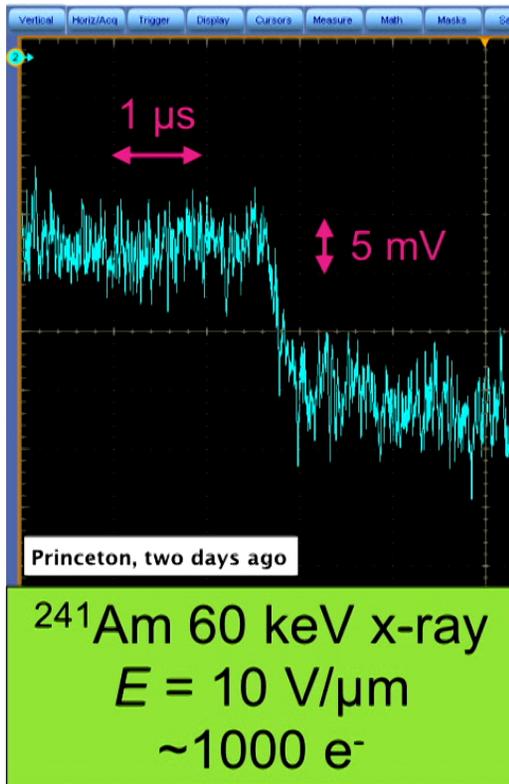


Specs: 20  $\mu\text{V}/e^-$   
20  $e^-$  noise

NIMA 812 (2016) 17

← Components distributed for setups in Waterloo, Princeton and Chicago.

# First single x ray pulse!



Goal: decrease noise further to do measure signal pulses with high resolution.

Perform calibration campaign with x rays of increasing energy.

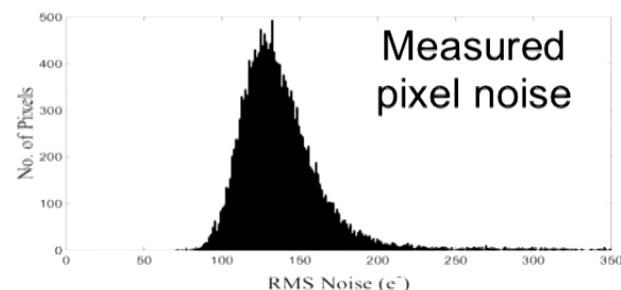
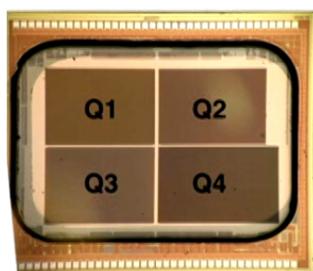
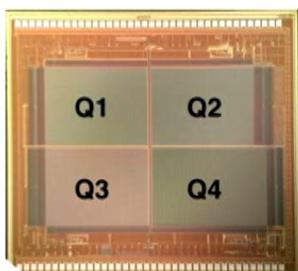
Size of step  $\propto$  charge generated.

Decay time dependent on drift and trapping of charge carriers.

**Pulse analysis to understand the properties of charge generation and transport in aSe.**

# CMOS implementation

Prof. Karim and Prof. Levine at UWaterloo have already been characterizing CMOS/aSe devices for imaging.



Will collaborate to test these devices for particle detection (starting with x rays).

As we understand aSe better from pulse shape analysis we will be able to evaluate the aSe/CMOS implementation and provide insight for pixel array design.

# CMOS device test

KA Imaging will release the Libra prototype for evaluation this fall:



Feature	Libra (1M)	Units
Pixel Pitch	7.8 x 7.8	$\mu\text{m}^2$
Array Resolution	1000 x 1000	pixels
Chip dimension	11 x 9	$\text{mm}^2$
Detector node Cap	58.4	fF
Conversion gain	2.74	$\mu\text{V}/\text{e}^-$
Operating Speed	$\leq 10$	fps
Input referred Noise	$< 150$ (@ $t_{\text{line}} = 100\text{ms}$ )	e-
Fill Factor	100	%
ADC	14	Bit
Full Well Pixel Capacitance	$>876$	Kelectrons
DQE (RQA5 beam)	$>15\%$ upto 40 lp/mm	%
A-Se Thickness	100 +/- 15	$\mu\text{m}$
Selenium HV Voltage	1500 max	Vdc
Conversion Gain	$<35$ @ 1500V (i.e. 15V/ $\mu\text{m}$ )	eV/electron
A-Se dark current	$<100$ (nominally 10)	$\text{pA}/\text{mm}^2$
Included Software	GUI executable, optional Verilog code for custom timing and control modification	

Also a **15x15**  $\text{cm}^2$  device with **50x50  $\mu\text{m}^2$**  pixels next year.

We plan to test and optimize these devices for particle detection in the lab.

# Conclusions

- CMOS/aSe technology could have the capability to reach backgrounds at the level of  $10^{-6} \text{ kg}^{-1} \text{ y}^{-1}$  in  $0\nu\beta\beta$  ROI.
- Most of the required specifications for the devices can be met in the next few years.
- Existing capabilities in industry will help with scalability.
- Ongoing **R&D** to determine the intrinsic response of aSe to radiation.
- Near-term **R&D** to characterize CMOS/aSe device implementation for particle detection.